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| APPLICATION | FILING or   | GRP ART |               |                |            |            |
|-------------|-------------|---------|---------------|----------------|------------|------------|
| NUMBER      | 371(c) DATE | UNIT    | FIL FEE REC'D | ATTY.DOCKET.NO | TOT CLAIMS | IND CLAIMS |
| 10/534 699  | 01/22/2009  | 1792    | 1480          | 063254-0233-US | 29         | 2          |

**CONFIRMATION NO. 6905** 

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FILING RECEIPT

Date Mailed: 04/24/2009

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please submit a written request for a Filing Receipt Correction. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections

# Applicant(s)

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# **Assignment For Published Patent Application**

Dupont Air Products NanoMaterial L.L.C.

#### **Power of Attorney:**

Christopher Hayden--44750

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/US03/36618 11/13/2003

#### **Foreign Applications**

JAPAN 2002-329464 11/13/2002

## If Required, Foreign Filing License Granted: 04/21/2009

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/534,699** 

Projected Publication Date: 08/06/2009

Non-Publication Request: No

Early Publication Request: No

#### Title

Chemical mechanical polishing composition and process

# **Preliminary Class**

438

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